

A2 10. (Amended) The resist stripper according to Claim 1, wherein the hydrogen peroxide and the quaternary ammonium salt are peroxyhydrate of the quaternary ammonium salt.

**Please add the following new claims:**

23. (New) The resist stripper according to Claim 10, wherein the peroxyhydrate of the quaternary ammonium salt is peroxyhydrate of tetramethylammonium hydroxide.

A3 24. (New) The resist stripper according to Claim 10, wherein the peroxyhydrate of the quaternary ammonium salt is peroxyhydrate of tetraethylammonium hydroxide.

25. (New) A resist stripper which consists of hydrogen peroxide, a quaternary ammonium salt, water and an amine.

26. (New) A resist stripper which consists of hydrogen peroxide, a quaternary ammonium salt, water and a water soluble organic solvent.

27. (New) The resist stripper according to Claim 26, wherein the water soluble organic solvent is at least one member selected from the group consisting of a sulfoxide, a sulfone, an amide, a lactam, an imidazolidinone, a glycol and a glycol ether.

28. (New) The resist stripper according to Claim 26, wherein the water soluble organic solvent is dimethyl sulfoxide.

AMENDMENT UNDER 37 C.F.R. § 1.111  
U.S. Appln. No. 09/996,773

29. (New) A resist stripper which consists of hydrogen peroxide, a quaternary ammonium salt, water, an amine and a water soluble organic solvent.

30. (New) The resist stripper according to Claim 29, wherein the water soluble organic solvent is at least one member selected from the group consisting of a sulfoxide, a sulfone, an amide, a lactam, an imidazolidinone, a glycol and a glycol ether.

31. (New) The resist stripper according to Claim 29, wherein the water soluble organic solvent is dimethyl sulfoxide.

A-3  
at